	Application No.	Applicant(s)	
Mating of Allowahility	10/523,491	FEIRING ET AL.	
Notice of Allowability	Examiner	Art Unit	
	John S. Chu	1752	
The MAILING DATE of this communication appeal All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this apply or other appropriate communication IGHTS. This application is subject to	plication. If not include will be mailed in due	ed course THIS
1. \boxtimes This communication is responsive to $2/21/07$.			
2. ☑ The allowed claim(s) is/are <u>1-45</u> .			
 Acknowledgment is made of a claim for foreign priority ur a)			
Certified copies of the priority documents have			
2. Certified copies of the priority documents have			
3. Copies of the certified copies of the priority do	cuments have been received in this	national stage applica	ition from the
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	of this communication to file a reply //ENT of this application.	complying with the re-	quirements
 A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give 	nitted. Note the attached EXAMINER es reason(s) why the oath or declara	'S AMENDMENT or Nation is deficient.	IOTICE OF
5. CORRECTED DRAWINGS (as "replacement sheets") mus	st be submitted.		
(a) including changes required by the Notice of Draftspers	son's Patent Drawing Review (PTO-	·948) attached	
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date			
(b) including changes required by the attached Examiner's Paper No./Mail Date	s Amendment / Comment or in the C	Office action of	
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t	.84(c)) should be written on the drawing the header according to 37 CFR 1.121(ngs in the front (not the	back) of
 DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT 	sit of BIOLOGICAL MATERIAL r FOR THE DEPOSIT OF BIOLOGIC	nust be submitted. I AL MATERIAL.	Note the
Attachment(s)			
1. Notice of References Cited (PTO-892)	5. Notice of Informal P	atent Application	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summary	(PTO-413),	
 Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date 	Paper No./Mail Dat 7.	nent/Comment	
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. 🛛 Examiner's Stateme	ent of Reasons for Allo	wance
or biological Material	9. Other		
			

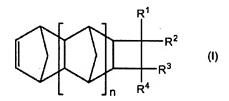
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REASONS FOR ALLOWANCE

1. The following is an examiner's statement of reasons for allowance: The claimed invention is drawn to the following:

A copolymer, a photoresist and a coated substrate comprising a substrate wherein the following copolymer is claimed:

(Previously Presented) A copolymer comprising a repeat unit derived from
 (a)at least one repeat unit derived from an ethylenically unsaturated
 compound having at least one fluorine atom covalently attached to an
 ethylenically unsaturated carbon atom; and
 (b)at least one repeat unit derived from an ethylenically unsaturated
 compound having the structure:



wherein n is 0, 1, or 2;

 R^1 , R^2 , R^3 and R^4 are independently H, OR^5 , halogen, alkyl or alkoxy of 1 to 10 carbon atoms, optionally substituted by halogen or ether oxygens, Y, $C(R_f)OR^5$, R^6Y or OR^6Y ;

Y is COZ or SO₂Z;

R⁵ is hydrogen or an acid-labile protecting group;

 R_f and R_f are the same or different fluoroalkyl groups of 1 to 10 carbon atoms or taken together are $(CF_2)_m$ where m is 2 to 10;

R⁶ is an alkylene group of 1 to 20 carbon atoms, optionally substituted by halogen or ether oxygen;

Z is OH, halogen, or OR7; and

 R^7 is an alkyl group of 1 to 20 carbon atoms, with the proviso that at least one of R^1 , R^2 , R^3 and R^4 is Y, OR^5 , $C(R_f)(R_f^4)OR^5$, R^6 Y or OR^6 Y, and the proviso that if R^1 (or R^3) is OH, R^2 (or R^4) is not OH or halogen.

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none of the prior art references of record disclose or anticipate the recited copolymer, a photoresist composition and a coated substrate comprising said copolymer having a structure of formula (I).

Accordingly, claims 1-45 are seen as allowable and passed to issue.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

2. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner Chu whose telephone number is (571) 272-1329. The examiner can normally be reached on Monday - Friday from 9:30 am to 6:00 pm.

If attempts to reach the Examiner by telephone are unsuccessful, the Examiner's supervisor, Cynthia Kelly, can be reached on (571) 272-1526

The fax phone number for the USPTO is (571) 273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PMR only. For more information about the PAIR

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system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

ohn S. Chu

Primary Examiner, Group 1700

J.Chu April 30, 2007